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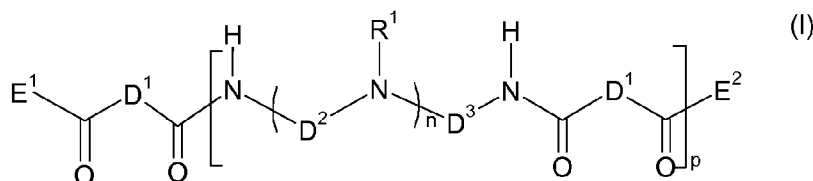
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(54) Title: COMPOSITION FOR METAL ELECTROPLATING COMPRISING LEVELING AGENT



(S7) Abstract: A composition comprising a source of metal ions and at least one additive comprising at least one polyaminoamide represented by formula (I) or derivatives of a polyaminoamide of formula (I) obtainable by complete or partial protonation, N-quarternisation or acylation.